

Department of Energy

Argonne Site Office 9800 South Cass Avenue Argonne, Illinois 60439

SEP 2 9 2014

Dr. Peter B. Littlewood Director, Argonne National Laboratory President, UChicago Argonne, LLC 9700 South Cass Avenue Argonne, IL 60439

Dear Dr. Littlewood:

SUBJECT: NATIONAL ENVIRONMENTAL POLICY ACT (NEPA) DETERMINATION FOR

ARGONNE NATIONAL LABORATORY (ARGONNE)

The Argonne Site Office (ASO) has approved the following as a categorical exclusion (CX) under Appendix B (to 10 CFR Part 1021, Subpart D, Integrated DOE NEPA Implementing Procedures, December 1996), Category B 3.15 "Small-scale indoor research and development projects using nanoscale materials" applicable to:

- Building 440 Center for Nanoscale Materials Clean Room Expansion (ASO-CX-306)

Therefore, no further NEPA review is required. However, if any modification or an expansion of the scope is made to the above project, additional NEPA review will be necessary.

Enclosed please find a copy of the approved Environmental Review Form (ERF) for the project. If you have any questions, please contact Kaushik Joshi of my staff at (630) 252-4226.

Sincerely,

Joanna M. Livengood

Manager

Enclosure: As Stated

CC.

J. Stauber, ANL, w/encl.

M. Finder, ANL, w/encl.

D. Tinnin, ANL, w/encl.

M. McKown, SC-CH, w/encl.

P. Siebach, SC-CH, w/encl.

K. Joshi, ASO, w/encl.



Environmental Review Form for Argonne National Laboratory

Project/	Acti	ivity Title: Building 440 CNM Clean Room Expa	nsion				
ASO NE	PA T	racking No. 1914 ASO- CX- 306	Type of Funding: IGPP				
			B&R Code				
Identify	ing I	number: 01422 WFO proposal #	CRADA proposal #				
Work Pr	ojec	et # : 08165 ANL accounting # (item	3a in Field Work Proposal)				
		ain) Cost Code: 0816500 Center: 208	lot.				
Project	Man	nager: Douglas J. Tinnin Signature:	eglas / moder 9/23/20/9				
		er: Michael P. Finder Signature:	1075 Date: 9/23/2014				
ANL NEF	PA R	eviewer: <u>Joel V. Stauber</u> Signature:	W. Stanty Date: 9/23/14				
	CNN stor facil	cription of Proposed Action: The proposed act of cleanroom building. The new addition will inclease and will consist of three major components. lities, and (3) instruments for characterization.	lude 10,000 ft ² (net) of floor space in two (1) conventional facilities, (2) fabrication				
		<u>cription of Affected Environment:</u> Previously of cture, adjacent to existing clean rooms.	listurbed area west of existing CNM				
III.	Pote	ential Environmental Effects: (Attach explanation	on for each "yes" response.)				
	A.	Complete Section A for all projects.					
	1.	Project evaluated for Pollution Prevention and Waste Minimization opportunities and details provided under items 2, 4, 6, 7, 8, 16, and 20 below, as applicable					
		Project will implement waste minimization opportunities and pollution prevention practices.					
	2.	Air Pollutant Emissions	Yes <u>X</u> No				
		Vehicle and construction equipment exhaust v	will be expected				

ANL-985 (12/06/2012)

1

3.	Nois	se	Yes X	No
		cal construction equipment noise will occur. Measures will be taken ring in accordance with OSHA.	to address	worker
4.	Che	mical/Oil Storage/Use	Yes X	No
		mical use and storage will be conducted in accordance with ANL procainers will be used when necessary.	cedures. Se	condary
5.	Pest	icide Use	Yes	No X
6.	Poly	chlorinated Biphenyls (PCBs)	Yes	No X
7.	Bioh	pazards	Yes	No X
	Greg	ent/Wastewater (If yes, see question #12 and contact gg Kulma (FMS-SEP) at 2-9147 or gkulma@anl.gov te Management	Yes	No X
	a)	Construction or Demolition Waste	Yes X	No
		Construction waste will be produced. Efforts will be made to recycl debris.	e construct	ion
	b)	Hazardous Waste	Yes	No X
	c)	Radioactive Mixed Waste	Yes	No X
	d)	Radioactive Waste	Yes	No X
	e)	PCB or Asbestos Waste	Yes	No X
	f)	Biological Waste	Yes	No X
	g)	No Path to Disposal Waste	Yes	No X
	h)	Nano-material Waste	Yes	No X
10	. Radi	iation	Yes	No X
11.	. Thre	eatened Violation of ES&H Regulations or Permit Requirements	Yes	No X
12	. New	or Modified Federal or State Permits	Yes	No X
13	Sitin	g, Construction, or Major Modification of Facility to Recover,	Yes	No X

Treat, Store, or Dispose of Waste

14.	Public Controversy	Yes	No X
15.	Historic Structures and Objects	Yes	No X
16.	Disturbance of Pre-existing Contamination	Yes	No X
17.	Energy Efficiency, Resource Conserving, and Sustainable Design Features	Yes X	No
	Design documents incorporate best practices sustainable design features. will be documented during construction.	These pra	ctices
В.	For projects that will occur outdoors, complete Section B as well as Section	on A.	
18.	Threatened or Endangered Species, Critical Habitats, and/or other Protected Species	Yes	No X
19.	Wetlands	Yes	No X
20.	Floodplain	Yes	No X
21.	Landscaping	Yes X	No
	Landscaping best practices will be used in accordance with Argonne Draft Management Guidelines.	Landscape	9
22.	. Navigable Air Space	Yes	No X
23.	. Clearing or Excavation	Yes X	No
	Excavation will be performed during construction. Erosion controls will be accordance with the Storm Water Pollution Prevention Plan.	implemer	nted in
24	. Archaeological Resources	Yes	No X
25	. Underground Injection	Yes	No X
26	. Underground Storage Tanks	Yes	No X
27	. Public Utilities or Services	Yes	No X
28	. Depletion of a Non-Renewable Resource	Yes	No X
C.	For projects occurring outside of ANL complete Section C as well as Secti	ons A and	В.
29	. Prime, Unique, or Locally Important Farmland	Yes	No

	30. Special Sources of Groundwater (such as sole source aquifer)	Yes	No
	31. Coastal Zones	Yes	No
	32. Areas with Special National Designations (such as National Forests, Parks, or Trails)	Yes	No
	33. Action of a State Agency in a State with NEPA-type Law	Yes	No
	34. Class I Air Quality Control Region	Yes	No
IV.	Subpart D Determination: (to be completed by DOE/ASO)		
	Are there any extraordinary circumstances related to the proposal that may affect the significance of the environmental effects of the proposal?	Yes	No X
	Is the project connected to other actions with potentially significant impacts or related to other proposed action with cumulatively significant impacts?	Yes	No X
	If yes, is a categorical exclusion determination precluded by 40 CFR 1506.1 or 10 CFR 1021.211?	Yes	No
	Can the project or activity be categorically excluded from preparation of an Environment Assessment or Environmental Impact Statement under Subpart D of the DOE NEPA Regulations?	Yes X	No
	If yes, indicate the class or classes of action from Appendix A or B of Subpart D project may be excluded. Appendix B, B. 3.15 Small-scale in development projects Using nanoscale materials. If no, indicate the NEPA recommendation and class(es) of action from Appendix Subpart D to Part 1021 of 10 CFR.	ndoor	research an
ASO N	IEPA Coordinator Review: Kaushik Joshi	- 2014	

ASO NCO Approval of CX Determination:

proposed action meets the requirements for the Categorical Exclusion identified above. Date: 9/24/2014 Signature: Peter R. Siebach Acting Argonne Site Office NCO SO NCO EA or EIS Recommendation: Not Applicable Class of Action: Signature: Date: Peter R. Siebach Acting Argonne Site Office NCO Concurrence with EA or EIS Recommendation: Not Applicable CH GLD: _____ Date: Signature: ASO Manager Approval of EA or EIS Recommendation: Not Applicable An EA EIS shall be prepared for the proposed and shall serve as the document manager. Dr. Joanna M. Livengood Manager

The preceding pages are a record of documentation that an action may be categorically excluded from further NEPA review under DOE NEPA Regulation 10 CFR Part 1021.400. I have determined that the





Basis of Design—Concept

prepared for

Argonne National Laboratory

June 02, 2014

submitted by:

M+W U.S. Inc., A Company of the M+W Group



Executive Summary

Argonne National Laboratory plans to construct additional cleanroom space at the Laboratory to benefit various programmatic needs across the Laboratory and support world-class science and the development of new technologies. Argonne conducted a siting feasibility study and determined that an expansion of the Center for Nanoscale Materials (CNM) Building 440 cleanroom facility presented the most advantageous location for this new facility.

The cleanroom expansion based on a preliminary tool list will involve adding approximately 6000 square feet of new footprint directly to the west of the existing CNM cleanroom space. The new cleanroom space, to be located on the ground floor with its supporting mechanical mezzanine on the second floor, will constitute approximately 12,000 square feet of new space. The general basis of design for the expansion is to simply extrude the existing cleanroom box. The design will copy the current CNM design and use it for new expansion, while taking into account any necessary improvements to meet current code or incorporate minor value lessons learned into the design.

Four alternative conceptual layouts were developed for this expansion for a preliminary list of potential tools. The tools required additional wall space which increased the footprint from the original planned 5000 sf to almost 6000 sf. One option was selected by Argonne and is the basis for this conceptual planning report.

Included herein is a list of major equipment elements, concept layouts of the 1st and 2nd floors of the proposed expansion, and a conceptual cost estimate for use by Argonne in planning and decisions.

The estimated cost of the project is \$6.1M. This exceeds the target originally set by Argonne of \$5.5M. Decisions regarding the building size and capital budget are now required before proceeding with design. Options can include:

- --reduction of the building footprint
- --partial buildout of interior space with a portion of the expansion shelled for future



Cleanroom

Major elements include:

Floor:

- Trenching will continue from existing to new footprint.
- Floor finishes: Bays ESD rubber tile (2x2) on concrete, Central Aisle ESD tile rubber tile (2x2).
- Chases CRC on floor surfaces and Trenches (vert. & horz. surfaces with galv. Grating on top).
- Trenches in Central Aisle CRC on Vert. & horz. surfaces with aluminum raised floor panel covers.

Walls:

 Standard 2" Cleanroom wall system (non-progressive) with 25% glazing. Sliding doors and manual doors. Wall design to match existing.

Ceiling Grid: (10'-0" high)

- Aluminum T-grid, Walkable 2x4 & 4x4 with lighting, blank pans, ducted HEPAS, sprinkler penetrations, ect.
- · Ceiling support: Unistruts, turn buckles, threaded rods, plenum barriers.

Arch. (Demolition) -

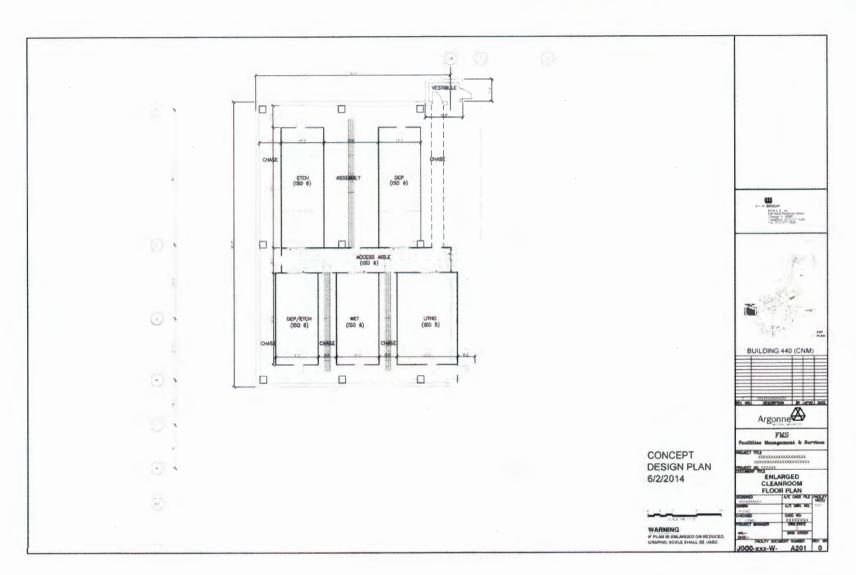
Exterior wall assembly:

- Remove entire exterior skin assembly (metal ribbed panel). Shear wall at north to remain. South wall remove completely.
- Air intake louver (Doghouse) on roof: Remove west wall to prep. For extension into new roof footprint.

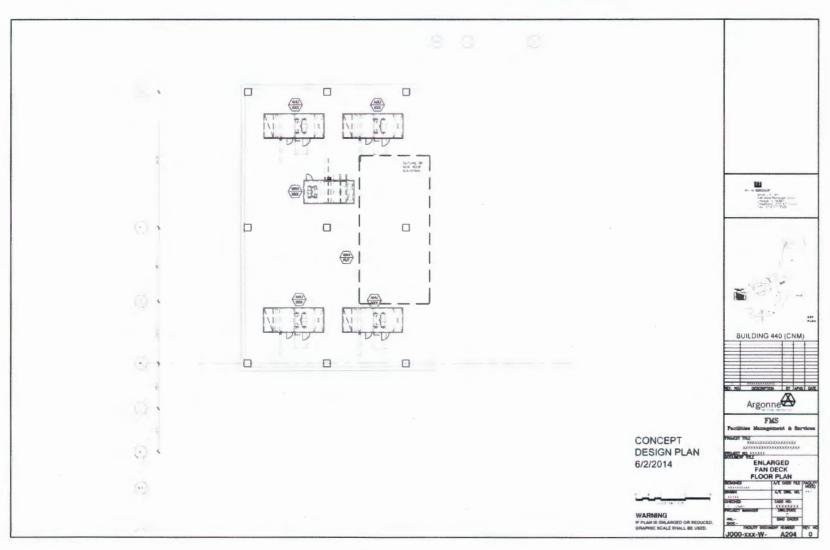
Arch. (New) -

- Exterior wall assembly/Skin (ribbed panel) to match existing (for both levels)
- Roof: Match existing (single-Ply roofing on rigid insulation)
- Fandeck Floor: match existing (concrete sealer). Provide 6" high curbing at perimeter.
- HM ext. doors to match existing (including hardware).
- South wall of fandeck- provide 10wx12h removable wall for equipment move-in.
- New 10x10 vestibule at L1 Cleanroom North wall











Mechanical

Major equipment units include:

- Four Cleanroom Recirculating Air Handling Units RCUs. (2) 24,000 cfm and (2)
 14,000 cfm
- Sixty (60) Ducted ULPA filters,
- 12 FFU's with ULPA filters for access corridor.
- 4 sensible cooling coils for access corridor.
- One Air Handling Unit (AHU) sized for the Fan deck (6,000 cfm, 15 hp, cooling coil, heating coil, heat recovery coil [heat pipe or run around coil], filters and distribution ductwork)
- Exhaust fan(s)
 - 1 − 26,000 cfm Strobic (Laboratory, induced draft, roof mounted) exhaust fan − 40 hp motor
 - 1 Inline exhaust fan for fan deck ventilation 7-1/2 hp.
- Two Tertiary pumps assume 3 hp, inline pumps.
- One HW PHC pump for AHU. (assume 1 hp, inline)
- One 10 gallon Hot water heater with a 5 kW heater.

Electrical

Major equipment units include:

- One 800A 480/277V distribution panel for tool power
- Two 225kVA 480V to 208/120V K-13 rated transformers for tool power
- Two 800A 208/120V distribution panels for tool power
- Six 225A 208/120V panelboards for tool power
- One 800A 480/277V distribution panel for mechanical equipment and other facility loads including lighting and general use receptacles
- One 225A 480/277V panelboard for lighting
- One 75kVA 480V to 208/120V transformer for general use receptacles
- One 225A 208/120V panelboard for general use receptacles
- One 100A 208/120V panelboard for general use receptacles
- One 100A 208/120V panel for emergency power
- Cleanroom lighting
- Lighting in the fan deck
- No exterior lighting other than building exit
- Lightning protection
- VFDs for mechanical equipment
- Plug-in busway for power distribution is planned in future when tool set is identified. This is excluded in expansion scope.



Controls

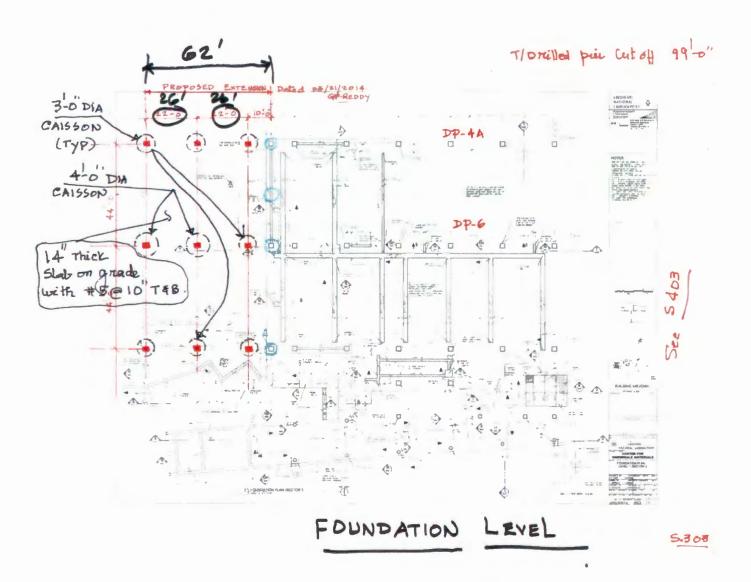
Major equipment units include:

- Furnish and install a complete system of temperature and safety controls. In general, all sensors and controls shall be electronic direct digital control (DDC) with pneumatic damper actuators and electric valve actuators. The system shall be complete with:
 - o DDC field controllers with indicating display
 - Electronic sensors and relays
 - Control and indicating panels
 - Electric wiring
 - Dampers and control valves
 - o Fire alarm system interface
 - The controls shall be integrated into the existing building automation system (BAS) with direct digital control that is to be microprocessor-based with an enhanced graphics color monitor, keyboard and a read/write printer.
 - System must be Johnson Metasys or Owner approved equal

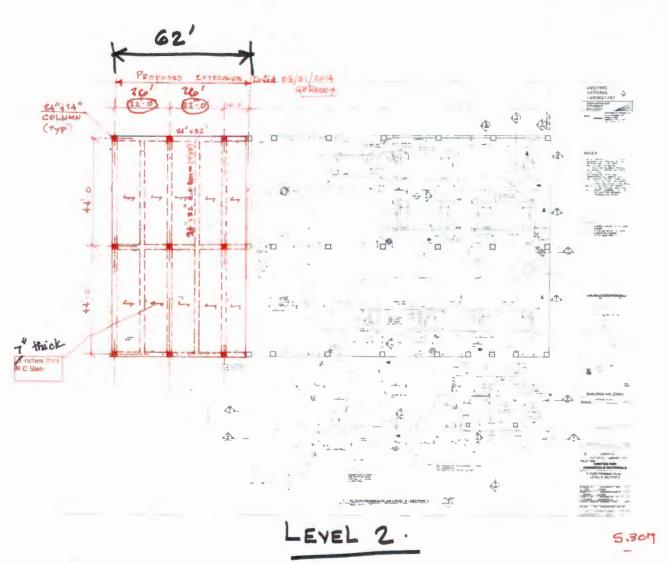


Structural

Structural elements are indicated on the following sketches:









Civil

Major elements include:

The scope of this work includes topsoil stripping and stockpiling (assumed 8") over the area of the building addition up to 15' outside of proposed walls, sidewalk removal around the south and east side of existing lab, proposed PCC sidewalk, 5" around and graded away from the building along the existing and new north wall, new west wall and new south wall; topsoil placement and grass seeding along the new sidewalk areas, perimeter and stockpile erosion control and disposal of excess topsoil.

Excluded are modifications to the saw-tooth dumpster area retaining walls in the loading dock. Excluded are any underground utilities or stormwater management work as all services (electric, gas, communication, sanitary, potable water, roof drainage, etc.) are all served from/to the existing building, the addition location does not impact any buried utilities we are aware of and Argonne staff have stated there is enough capacity in the existing facilities for this addition.



Process

Preliminary equipment list includes:

System	Quantity	Unit	Comments
JPW			
JPW5 main, 1-1/2" PVDF	180	ft	Cut into existing 2" on Level 2 - requires system shutdown and flush to quality
JPWR main, 1-1/2" PP	180	ft	Cut into existing 1 1/2" on Level 2 requires system shutdown and flush to quality
UPWS laterals, 1" PVDF	144	ft	
IPWR laterals, 1" PP	144	ft	
Diaphragm valves, 1" PVDF	4	each	Lateral isolation valves + future
Diaphragm valves, 1" PP	4	each	Lateral isolation valves + future
Diaphragm valves, 1/2" PVDF	74	each	
Diaphragm valves, 1/2" PP	24	each	
End-of-main loop	1	each	w/ bypass, rotometer, guages, isolation valves, PT, CV
End-of-lateral loops	3	each	w/ bypasses, rotometers, guages, isolation valves
Hangers/supports			
PCW			
PCWS main, 4" 3041 SS Sch 10	96	ft	Hot tap into existing 6" on Level 2 (no futures found)
PCWR main, 4" 3041 SS Sch 10	96	ft	Hot tap into existing 6" on Level 2 (no futures found)
PCWS laterals, 2" PVC Sch 80	240	ft	
PCWR laterals, 2" PVC Sch 80	240	ft	
Ball valves, 2" 55	12	each	Lateral isolation valves + future
Ball valves, 2" PVC	80	each	POC valves
End-of-main loop End of lateral loops	5	each each	w/ hypass, rotometer, guages, isolation valves, PT, CV w/ bypasses, rotometers, guages, isolation valves
Hangers/supports	5	eacn	w/ bypasses, rotometers, guages, isolation valves
Hangers/supports			
CDA			
CDA main, 1-1/2" Type L copper, CFOS	72	ft	EOM reduces to 1/2" - cut off 1/2" valve and install 1-1/2" valve - requires system shutdown.
CDA laterals, 3/4" Type L copper, CFOS	240	Ħ	
Ball valves, 3/4" bronze, CFOS	6	each	Lateral isolation valves + future
Ball valves, 1/2" bionze, CFOS	40	each	
Hangers/supports			
PVAC		_	
PVAC main, 4" PVC Sch 80	96	ft	Cut into existing 4" on Level 2 - requires system shutdown
PVAC laterals, 2" PVC Sch 80	240	ft	
Ball valves, 2" PVC	6	ft	Lateral isolation valves + future
Ball valves, 1" PVC	40	each	
Hangers/supports			
N2			
Nitrogen main, 1-1/2" 316L EP 55	144	ft	Connect to existing valve on Level 2
Nitrogen main, 1" 316L FP SS	240	ft	
Diaphragm valves, 1" SS EP	6	each	Lateral isolation valves + future
Diaphragm valves, 1/2" SS FP	40	each	
Hangers/supports			
Acid Waste			
AW main, 4" PVC Sch 80	72	ft	
AW laterals, 3" PVC Sch 80	144	ft	
Capped POCs, 2" x 3" wyes Trench supports	24	each	
Detergent Waste			
DTGW main, 4" PVC Sch 80	72	Ħ	
DTGW laterals, 3" PVC Sch 80	144	ft	
Capped POCs, 2" x 3" wyes Trench supports	24	each	

- Assumptions:

 1) Existing systems have sufficient capacity to serve the expansion; no system upgrades required

 2) Main line sizes based on 1/2 of existing system capacities

 3) Lateral sizes match existing CNM cleanroom laterals

 4) Lateral length ~ 40 feet

 5) Three (3) Laterals provided for UPW and Waste; all other services have (5) laterals

 6) Each lateral has 2x the number POCs as existing CNM Laterals

 7) 70% contingency added to all pipe lengths

Worksheet in C. Users doumnings AppData Local Microsoft Windows Temporary Internet Files Contant. Outlook U9UZIF8W BOD Concept.docx



Life Safety/ Telecom/Security

Major equipment includes:

Code required systems for fire and smoke detection, alarms, and tie-in to existing system.

Leak detection and TGMS devices and connections are to be designed and procured by owner when the tool set is identified and funded. These are excluded from the expansion project.

An allowance has been established for Telecom devices and connection to existing system.

Security systems have been excluded since the building is a secure facility.



Preliminary Tool List

Preliminary 1001 List	Width (ft)
Assembly: BlackStar SW300 Laser Dicer	7
Assembly: Flip chip bonder	4
Assembly: Wafer bonder	4
Assembly: Wire bonder	4
Deposition: ALD	6
Deposition: ALD	6
Deposition: Ebeam evaporator (for liftoff)	8
Deposition: LPCVD (if possible)	10
Deposition: LPCVD tube cleaning	10
Deposition: PECVD (Nitride)	10
Deposition: PECVD (Oxide)	10
Etch: Chemically assisted Ion beam mill	10
Etch: XeF2 Etch System	4
Gas cabinets	0
Gas Manifolds	0
LF Hood: develop, rinse, dry (Plastic)	6
LF Hood: Electroplating (plastic)	6
LF Hood: general (plastic)	6
LF Hood: HF Wet Etch Hood (plastic)	6
LF Hood: metal wet etch (SS)	6
LF Hood: RCA clean hood or track (plastic)	6
LF Hood: resist removal and Liftoff (SS)	6
LF Hood: Spin Coat and Bake (SS)	6
LF Hood: TMAH + KOH wet bench (plastic)	6
Metrology: Automated imager	4
Metrology: HRSEM	8
Metrology: Optical LEXT profilometer (Large area, stitching capable)	4
Metrology: Optical microscope	6
Metrology: Optical microscope	6
Metrology: Optical microscope	6
Metrology: Optical stress tool (FLEXUS)	4
Metrology: Probe station	4
Metrology: SEM for MEMS	8
Metrology: Spectroscopic Variable Angle Ellipsometer	6

Argonne BOD Concept



M+W GROUP

Metrology: White light interferometer	4
Optical Litho: Heidelberg pattern generator	8
Optical Litho: MA / BA 6 with backside alignment	4
Optical Litho: Stepper (i-line)	10
Oven: Vapor priming image reversal oven (add ammonia)	4
Oven: Vapor priming oven	3
Process: Mask cleaning tool	4
Process: Ultrasonic sonicator inside hood 3 ft x 3 ft	
Process: Wafer spin rinse dryer	4
RIE: DRIE (fab grade)	10
RIE: Fluorine (Nb etch + SiO2 + SiNx)	10
RIE: Metal etch	10
RIE: resist asher	4
Sputtering: AJA multi-target sputtering system (for all sputtering)	10
Sputtering: AJA multi-target sputtering system (for all sputtering)	10
Sputtering: with oxidation chamber for junctions	10
Sputtering: WSix sputter deposition tool	10
Storage: Corrosive cabinets	6
Storage: Flamable cabinets	6
Storage: Glass ware cabinets	6
Storage: Mask Storage	14
Storage: Wafer storage	· 14
Tables for samples	4
Wafer track: bake, develop, rinse, dry, resist removal	14
Wafer track: spin coat and bake (2 step LOR process)	14
Linear Wall Space Required (including clearnances) in feet	396
Wall space available with 3 30' bays	180
Wall space available with 3 40' bays	240
Total wall space available	420
Required / Available (or utilization)	94%